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Controlling Material Properties of Nanostructured WS<sub>2</sub> during Plasma-Enhanced Atomic Layer Deposition for Improved Electrochemical Performance



Fig.1. (a, b) Scheme for the WS<sub>2</sub> nanoflakes and WS<sub>2</sub> fin growth. (c, d) Cross-section transmission electron microscopy (TEM) images of WS<sub>2</sub> nanoflakes and fins. (e, f, g) Top-view TEM images of WS<sub>2</sub> nanoflakes, fins and stack (nanoflakes on top of fins), respectively.



Fig.2. Hydrogen evolution reaction (HER) performance of  $WS_2$  nanostructures – nanoflakes, fins, and stack (nanoflakes on fins), shown in a typical linear sweep voltammetry (LSV) plot. Table 1. Sulfur to tungsten ratio and mass density of  $WS_2$  nanoflakes and fins, as deduced from Rutherford backscattering spectroscopy (RBS) measurements.